# An Optimized Measurement Algorithm for Gas Sensors Based on Carbon Nanotubes: Optimizing Sensor Performance and Hardware Resources

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Abstract—This paper presents a novel algorithm for the 2 measurement of resistive-type gas sensors with carbon nan-3 otubes (CNTs) as sensitive layer. Contrary to conventional 4 strategies, which extract the sensor information from the normal-5 ized resistance, the proposed algorithm is based on the variation 6 in resistance over time. The results have demonstrated that the 7 time necessary to get the maximum performance of these sensors <sup>8</sup> is reduced around a 25% when compared with the conventional 9 approach for any of the recovery strategies analyzed (passive 10 desorption, external heating, or dc voltage). The hardware imple-11 mentation of the proposed algorithm in a field-programmable 12 gate array (FPGA) has also demonstrated that, in addition to 13 optimizing the sensor performance in terms of time response 14 and sensitivity, this measurement algorithm yields a significant 15 minimization of the sensor readout circuit resources at both soft-16 ware and hardware levels paving the way for future development 17 of smart sensors for the Internet of Things (IoT) applications.

Index Terms—Carbon nanotube (CNT), field-programmable
gate array (FPGA), inkjet printing, NH<sub>3</sub>, recovery, single-walled,
spray deposition.

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# I. INTRODUCTION

RECENTLY, gas leakage detection is a topic of high interest in diverse fields from personal to industrial applications. In this context, thanks to the rapid advances in the development of wireless sensors devices into the Internet of Things (IoT) paradigm, there is a current trend toward the ubiquitous sensing. However, significant challenges remain concerning the widespread availability of this kind of devices for end-user applications. On the one hand, sensors need to be lightweight, low-power, robust, and small in size and, on the other hand, the algorithms implemented in the IoT devices must be optimized to minimize both computing resources and time, and consequently, the power consumption.

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Therefore, it is clear that the convergence between nanotechnology (new materials and detection methods, manufacturing processes, device integration, etc.) and both measuring and processing algorithms is mandatory to move forward in this effort [1].

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Regarding gas sensors, resistive ones are very popular 39 because of their reasonable price and good durability [2]. 40 However, they are commonly limited in their selectivity and 41 sensitivity, boosting research to develop new materials and 42 detection methods for a better gas discrimination [3]. In this 43 direction, functional materials have received a lot of atten- 44 tion. A large variety of electrical sensor materials have been 45 investigated, including semiconducting metal oxides, silicon 46 devices, organic materials, carbon nanotubes (CNTs) and car-47 bon black-polymer composites [4]. These new materials are 48 normally tuned by functionalizing them with metal and poly-49 mers to achieve selectivity toward certain gas species [5]; 50 however, the vast majority of the solutions are time and 51 power demanding. Therefore, several approaches have been 52 developed toward facing these issues, for instance, higher-53 order sensing systems which consist of sensor arrays covered 54 with different sensitive layers [6], using pattern recognition 55 algorithms [7], or multifunctional sensors which measure different properties of a sensitive layer [8]. Furthermore, it is 57 desirable to recover the sensor response over time, that is to 58 say, to desorb the trapped molecules in the sensing element 59 after being exposed to the gas. A common strategy to recover 60 the sensing layer is to externally heat the sensor to increase 61 the desorption rate of the trapped molecules [9]–[11]. This 62 approach normally requires the integration of more circuitry 63 and higher power consumption. Recently, we have reported 64 the capability of CNTs gas sensors to self-recover by apply-65 ing a higher than probing dc voltage between its terminals, 66 reducing the power demand of the system as well as not 67 requiring more circuit elements for the recovery stage [12]. 68 A lot of effort has been put in developing this kind of gas 69 sensor because they present high sensitivity toward a vari-70 ety of gas species [5], [13], [14], can be manufactured with 71 cost-effective techniques [15], [16] and can be deposited on 72 flexible substrates [17], [18], providing a promising starting 73 point for the industrial use of this technology. However, very 74 limited attention has been paid to their transduction mecha-75 nisms in terms of the requirements to be integrated at system 76 level. 77

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<sup>78</sup> Conventionally, the information of resistive sensors is <sup>79</sup> extracted from their normalized resistance (NR). In other <sup>80</sup> words, it is measured the relative change in resistance when <sup>81</sup> the sensor is exposed to the parameter of interest with respect <sup>82</sup> to its value under base level conditions [10], [19], [20]. One <sup>83</sup> essential part of any sensory system, mostly neglected by basic <sup>84</sup> research, is the integration of the sensing element in a com-<sup>85</sup> plete electronic system. This requires the design of circuits to <sup>86</sup> adapt the sensor signal and efficiently and accurately extract <sup>87</sup> the sensor information [21].

In this paper, we propose a new algorithm to analyze the 88 89 response of a CNT gas sensor based on its relative change 90 of resistance over time and we demonstrate its superior-91 ity over the NR, the conventional approach, at the sensor 92 performance and at the employed hardware resources for 93 extracting information. We investigate this novel approach in 94 terms of time response, sensitivity, and level of integration 95 in final systems. One of the most desirable aspects in the <sup>96</sup> field of instrumentation is to bring the intelligence to the sen-97 sor elements through the applications of low computational 98 cost, small size, and low consumption. Thus, the measure-<sup>99</sup> ment algorithm proposed in this paper allows optimizing the 100 resources of implementation and computation, making feasible the future development of a smart sensor, crucial for the 101 <sup>102</sup> truly development of the paradigm of the IoT.

This paper is organized as follows. In Section II, the design and fabrication of the sensor is described together with its characterization procedure. Section III describes the proposed algorithm and presents its empirical results in comparison with the conventional method. At the end of this section, the it is analyzed the system requirements of each approach and their feasibility of circuitry integration. Finally, the main conclusions are drawn in Section IV.

### II. MATERIALS AND METHODS

# 112 A. Fabrication Process

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Initially, we sprayed the CNT solution on the polyimide 113 substrate (Kapton HN) of 125  $\mu$ m-thickness. The CNTs were 114 115 dispersed in an aqueous solution based on 1 wt.% sodium 116 dodecyl sulfate (SDS). After stirring the solution for 1 h, 117 0.03 wt.% CNTs were added to the dissolved dispersion agent. The obtained solution was sonicated for 30 min using horn 118 sonicator at 50% of its maximum power (~48 W). After 1.5 h 119 120 of centrifugation at 15000 rpm, the top part of the solutions 121 was removed from the vials to be used for the deposition, while 122 the bottom 20% was disposed. By mounting an air atomizing 123 spray valve (Nordson EFD, USA), to a motorized X-Y plat-124 form (Precision Valve & Automation, USA), it was possible obtain a repeatable spray process, using an approach similar 125 to what previously reported [17], [18]. After deposition, the 126 to 127 samples were immersed in deionized water for 15 min at room <sup>128</sup> temperature to remove the dispersant, and subsequently dried. Then, on top of the CNT film, we defined the electrodes, 129 130 using a DMP-2831 Dimatix printer (Fujifilm Dimatix, Inc., <sup>131</sup> Santa Clara, CA, USA) fixing the plate temperature during the <sup>132</sup> printing at 60 °C. The electrodes were made of one layer of sil-<sup>133</sup> ver nanoparticles (DGP 40LT-15C from ANP Company, USA),



Fig. 1. (a) Schematics of the fabricated sensors. (b) Real picture of the sensor. (c) Schematic of sensor module.

defining the drop space to 50  $\mu$ m. The finger width and the space between fingers are 100  $\mu$ m and the finger length 3 mm. <sup>135</sup> After printing and drying of the electrodes, they were photonic <sup>136</sup> sintered (Sinteron 2010 from Xenon, USA) with five pulses <sup>137</sup> of 2.5 kV energy and 500  $\mu$ s width. Fig. 1(a) illustrates the layers of the manufactured device and Fig. 1(b) presents a real <sup>139</sup> picture of the developed sensor. <sup>140</sup>

The complete sensor module includes the resistive sensor, <sup>141</sup> mounted on a carrier glass together with a Peltier heating <sup>142</sup> element for temperature control and a temperature sensor <sup>143</sup> (Pt100) for *in-situ* monitoring [Fig. 1(c)]. <sup>144</sup>

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# B. Characterization Process

Sensors were measured by monitoring the variation in resis- 146 tance with respect to the test gas concentration. Before the 147 sensor response toward test gas was analyzed, the initial resis- 148 tance of the sensor was monitored over time to determine its 149 baseline. After reaching a stable initial value, the sensor mod- 150 ule was introduced inside a gas chamber and its response was 151 evaluated by exposing it to different concentrations of test gas. 152 Fig. 2 illustrates a measurement cycle, which is composed of 153 an exposure interval followed by a recovery interval and then 154 an interval at normal conditions. The room temperature was 155 set to circa 22°, and in each stage, nitrogen was employed 156 as carrier gas to be certain that the measurement result would 157 only be influenced by the target gas. In "normal conditions" 158 phases, the carrier gas flow was set to 200 ml/min. During 159 exposure phases, the overall mixture flux was set to a constant 160 200 ml/min for a given time at ambient temperature [stage (c) 161 in Fig. 2]. 162

Recovery was then introduced, following three different 163 strategies [stage (b) in Fig. 2]: 1) externally heating the sensor, with a Peltier cell, to 80 °C; 2) applying 10 V among 165 the sensor terminals to establish a self-heating condition; and 166 3) passive recovery (leaving the sensor under ambient conditions). For ease of comparison, every recovery strategy was 168 tested with the same conditions (unchanged room temperature, 200 ml/min flux of carrier gas). After these recovery 170



Fig. 2. Schematic of the measurement flow, pointing out the different stages. (a) Operation at normal conditions. (b) Recovery step. (c) Exposure to gas.

<sup>171</sup> phases, the high flux was kept once more at ambient condi-<sup>172</sup> tions [stage (a) in Fig. 2] to facilitate the recuperation of the <sup>173</sup> device and purge any residual test gas molecules out of the gas <sup>174</sup> chamber. Recovery stage ended by a final step under sensing <sup>175</sup> conditions (200 ml/min of carrier gas at ambient conditions) <sup>176</sup> to help restore the initial resistance before the next expo-<sup>177</sup> sure cycle. We performed two different measurement tests, <sup>178</sup> a longer one where all the steps in the cycle had a duration <sup>179</sup> of 300 s and a shorter one with the duration of the steps <sup>180</sup> fixed at 150 s.

The measurements were automated with LabVIEW 182 2016 software, which controlled an impedance analyzer 183 (Keysight E4990A) with an impedance probe kit (4294A1) for 184 the sensor readout (impedance). The excitation voltage applied 185 in all measurements was  $V_{dc} = 0$  and  $V_{ac} = 500$  mV and 186 the frequency swept ranged from 20 to 100 Hz. The dc volt-187 age to perform the recovery stage was directly applied by the 188 impedance analyzer. The phase in all frequencies was below 189  $10^{-30}$ , proving the virtually pure resistive behavior of the 190 device under test. In particular, the NH<sub>3</sub> concentrations tested 191 covered a range between 10 and 80 ppm, achieved by diluting 192 the test gas with nitrogen as carrier gas.

## III. RESULTS AND DISCUSSION

In this section, we will first show the analysis of the 194 195 described sensor using the proposed measurement methods <sup>196</sup> and comparing its performance with the conventional proce-<sup>197</sup> dure. After that, we will show the influence of the recovery <sup>198</sup> strategy in this new measurement protocol, followed by the 199 use of this protocol to the response of the sensor toward 200 other gases. Finally, we will show a study of the efficiency the described measurement protocol in comparison with of 201 <sup>202</sup> the conventional one in hardware and software final solutions. In the following sections, we present the mean values of 203 three complete measurements cycles. The errors are lower than 204 2% in all cases. 205

#### 206 A. Response to Ammonia

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In order to evaluate the sensor performance, the conventional measurement protocol is based on the NR presented in (1): the difference in resistance before and after the exposure divided by this initial resistance. What we propose is to fix the measurement time and only measure the variation in resistance in the chosen time slot, see (2)

Normalized Resistance(%) = 
$$\frac{K_f - R_i}{R_i}$$
 (1) <sup>213</sup>

Temporal Resistance Variation 
$$\left(\frac{\Omega}{s}\right) = \frac{R_f - R_i}{T}$$
 (2) 214

where  $R_i$  and  $R_f$  are the initial and final resistance values of <sup>215</sup> an exposure cycle, respectively, and *T* is the reference time <sup>216</sup> interval. Notice that once that after the calibration, an optimal <sup>217</sup> value of *T* will be found, it shall be considered as constant. <sup>218</sup> On the contrary, looking to (1), the initial resistance of the <sup>219</sup> CNT film cannot be considered as constant, since the baseline <sup>220</sup> value is not necessarily recovered after exposure. <sup>221</sup>

The time response of such gas sensing systems is traditionally modeled as a "charging" circuit, with a classic growing negative exponential response [22] 224

$$R(t) = R_i + \Delta R(C) \left(1 - e^{-\frac{t}{\tau}}\right)$$
(3) 225

$$R'(t) = \frac{\Delta R(C)}{\tau} e^{-\frac{t}{\tau}}$$
(4) 226

$$NR' = \frac{\Delta R(C)}{R_i \tau} e^{-\frac{t}{\tau}}.$$
 (5) 227

The derivative of the time evolution of resistance—and, <sup>228</sup> hence, the NR—after exposure is always strictly positive, as <sup>229</sup> presented in (4) and (6), respectively. This implies that the <sup>230</sup> NR will have an increasing value until the slope will be <sup>231</sup> only marginally increased, and saturation can be considered <sup>232</sup> reached. The saturation point, however, could be substantially <sup>233</sup> different, depending on the network properties. The proposed <sup>234</sup> characterization feature, on the other hand, focuses on the tem-<sup>235</sup> poral resistance variation (TRV), introduced in the previous <sup>236</sup> section. The TRV will quickly reach its maximum and then <sup>237</sup> decrease over time, toward a more stable value. Proceeding <sup>238</sup> similar to what we did for the NR, it is possible to write TRV <sup>239</sup> and its derivative as <sup>240</sup>

$$\operatorname{TRV}(t) = \frac{\Delta R(C)}{t} \left( 1 - e^{-\frac{t}{\tau}} \right)$$
(6) 241

$$\text{TRV}'(t) = -\frac{\Delta R(C)}{t^2} \left(1 - e^{-\frac{t}{\tau}}\right) + \frac{\Delta R(C)}{t\tau} e^{-\frac{t}{\tau}}.$$
 (7) 242

Thus, the derivative with respect to time of TRV is strictly <sup>243</sup> negative and quickly approaching zero. The maximum of the <sup>244</sup> TRV response will be observed immediately after exposure. <sup>245</sup>

Fig. 3(a) and (b) shows the NR while the sensor is exposed 246 to the test gas, whereas Fig. 3(c) and (d) presents the TRV 247 during the test gas exposure. In particular, Fig. 3(a) and (c) 248 corresponds to 150 s exposure while Fig. 3(b) and (d) to 300 s. 249 It can be observed how the shapes of the curves are indepen- 250 dent on the exposure time. In the case of the NR, the sensor 251 has not achieved the saturation point. If the exposure takes 252 longer, it is expected to have an increase in the NR and, there- 253 fore, the response of the sensor would be higher, the longer 254 the exposure is. Contrary to this behavior, the TRV depicts 255 a faster increase in its response around the first 50 s exposure 256 and it tends to a constant value above 120 s. This response 257 provides us a new resource to characterize this sensor, ensur- 258 ing a stable value and, especially, facilitating its integration in 259 final systems. 260



Fig. 3. NR over time for different NH<sub>3</sub> concentrations with an exposure time of (a) 150 s and (b) 300 s. TRV over time at the same NH<sub>3</sub> concentrations with an exposure time of (c) 150 s and (d) 300 s.



Temporal resistance variation versus ammonia concentration at Fig. 4. different exposure times.

The calibration curve of the sensor considering the TRV 261 over NH<sub>3</sub> concentration is illustrated in Fig. 4, selecting 262 three different point of time. At 74 s, the response is slightly 263 higher than at longer time exposure. Contrary to the traditional 264 265 measurement (NR), longer exposure time does not ensure 266 a better response of the sensor.

Basically, when using NR, the response achieves its maxi-267 <sup>268</sup> mum at saturation and to reach this point we have to wait until 269 the resistance stabilizes (meaning in this case, a time longer 270 than 300 s). Opposite to this approach, when applying TRV, how fast the resistance changes with the concentration exhibits 271 272 an increase at the beginning until reach a maximum (in this 273 case, about 75 s) and then stabilized.

The linear regression curves extracted from data in Fig. 4 are 274 275 presented in (8)-(10) for 74, 89, and 104 s, respectively

<sup>276</sup> TVR(
$$\Omega/s$$
) = 0.01844 · [NH<sub>3</sub>] + 0.50105,  $R^2 = 0.95138$  (8)

<sub>277</sub> TVR(
$$\Omega/s$$
) = 0.01631 · [NH<sub>3</sub>] + 0.51455,  $R^2$  = 0.97501 (9)

(10)

<sup>278</sup> TVR(
$$\Omega/s$$
) = 0.01603 · [NH<sub>3</sub>] + 0.50833,  $R^2$  = 0.96319.

Notice an important improvement that TRV achieves com- 280 pared to the NR for the integration of the sensing element in 281 a complete electronic system. For the computation of the NR 282 it can be observed that (1) includes a division to an arbitrary 283 real number (the measured initial resistance value). This arith- 284 metic operation, albeit important, is far more complex than 285 addition and multiplication, and requires significant amount of 286 resources for a complete hardware implementation [23], [24]. 287 Thus, a challenge, sometimes difficult to achieve, is to be able 288 to manipulate the algebraic expression in order to convert it 289 into another one that only includes multiplications and/or addi- 290 tions. Achieving the above would make it possible to get an 291 area reduction and performance improvement of the hardware 292 implementation, a very important aspect to be able to provide 293 a competitive portable design. In this sense, for the computa- 294 tion of the TRV, (2) matches the requirements of the previous 295 challenge, since the term T is a constant value, statically cho- $^{296}$ sen in design phase, and the division by this constant can be 297 easily converted into a multiplication [25]. Thus, in addition 298 to the advantage related to the faster increase in its response, 299 the TRV facilities the integration in final systems. 300

Similar results have been found for ethanol (see Fig. S1), 301 demonstrating the wider use of the proposed algorithm. 302

Muezzinoglu [26] also proposed an analysis of the tran- 303 sient response of chemo-resistive sensors providing a faster 304 response without waiting until the sensor achieve the equilib- 305 rium point. However, in their approach, it is needed to employ 306 various multiplications; while, in our algorithm, only one sim- 307 ple multiplication is needed. Moreover, contrary to them, we 308 demonstrate that no data transformation is needed to extract 309 the sensor information. 310

## B. Response Using Different Recovery Strategies

The recovery of the sensor to its baseline after finishing the 312 exposure to the gas is an important feature of any gas sen- 313 sor, although the vast majority does not completely recover 314 to their baseline but they show substantial drifts after differ- 315 ent exposure cycles [27], [28]. SWNT gas sensors are one of 316 those devices that do not recuperate the baseline at ambient 317 conditions after exposure to a test gas [29]. In order to force 318 the sensor to recover its initial characteristics, it is necessary 319 to provide extra energy in the form of heat or gate biasing or 320 UV light [29]-[32]. The data presented in Figs. 3 and 4 cor- 321 responds to a recovery strategy based on external heating (in 322 this case, at 80 °C), as this is the most established approach. 323 Nevertheless, recently it has been proved that a similar effect 324 can be achieved by applying a dc voltage [12]. Even in this 325 case, however, the power demand of the sensing system is sig- 326 nificantly higher than what a simple resistance measurement 327 would require. Resultantly, an even more remarkable finding 328 would be to avoid the recovery to the baseline, leaving the 329 sensor to passively get rid of the trapped molecules (passive 330 recovery), and still be able to guarantee high and repeatable 331 response. 332

Fig. 5 shows the analysis presented in the previous section 333 for dc voltage recovery [Fig. 5(a) and (b)] and for passive 334 recovery [Fig. 5(c) and (d)]. The shapes obtained are similar 335

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Fig. 5. (a) NR over time for different NH<sub>3</sub> concentrations with an exposure time of 300 s and recovery at 10 V. (b) TRV over time at the same NH<sub>3</sub> concentrations with an exposure time of 300 s and recovery at 10 V. (c) NR over time for different NH<sub>3</sub> concentrations with an exposure time of 300 s and passive recovery. (d) TRV over time at the same NH<sub>3</sub> concentrations with an exposure time of 300 s and passive recovery.

to the external heating recovery for both NR and TRV. When we look at the NR, the active recovery strategies (heating at 838 80 °C and applying 10 V) achieve around 2.5% at 80 ppm 839 NH<sub>3</sub> after 300 s, while the response is below 2% for passive recovery at the same concentration and point of time. But when 840 recovery at the TRV, this difference is reduced. For example, 842 we measured 1.9 Ω/s at 80 ppm NH<sub>3</sub> and 74 s for heating 843 recovery, 2.0 Ω/s for dc voltage recovery, and 1.8 Ω/s for 845 active recovery case is 18% and 5% for the NR and TRV 846 methods, respectively.

### 347 C. Performance in Real Measurement Instrument

Hardware implementation in field-programmable gate 348 349 array (FPGA) of NR and the new proposal based on TRV have been evaluated and compared. Fig. 6 shows 350 the block diagram of TRV implementation that is based 351 on a finite-state machine (FSM) implementation. VHDL 352 353 descriptions of the developed designs have been implemented <sup>354</sup> using Spartan 6 xc6vlx40t-1fgg1156 [33] and Cyclone II 355 EP2C20F484C7 [34] devices from Xilinx and Intel (formerly, <sup>356</sup> Altera), respectively. The architectures have been designed for 357 two different exposure times, 128 and 256 s. These exposure 358 times are within the range of interest and have been selected <sup>359</sup> since to divide by a power of 2 using binary representation is 360 equivalent to displacements to the right of the data record, <sup>361</sup> thus reducing the required area resources. In order to get <sup>362</sup> these exposure times, the designs were developed taking into <sup>363</sup> account the frequencies of the clock sources coming into the 364 FPGA devices. 200 and 50 MHz clock sources were used for 365 Spartan 6 and Cyclone II devices, respectively.



Fig. 6. (a) Block diagram of TRV or NR algorithm implemented in FPGA. (b) VHDL sentences for NR output logic for NR algorithm. (c) VHDL sentences for TRV output logic (for an exposure time of 128 s).

TABLE I Area and Delay Figures for FPGA Implementation Using an Exposure Time of 128 s

	Spartan 6				
Design	Area (Slices)	Ratio	F <sub>max</sub> (MHz)	Ratio	
NR	99	1	29.49	1	
TRV	25	0.25	478.87	0.06	
	Cyclone II				
Design	Area (LEs)	Ratio	F <sub>max</sub> (MHz)	Ratio	
NR	374	1	20.27	1	
TRV	83	0.22	189.04	0.11	

Tables I and II summarize the area and maximum frequency <sup>366</sup> figures for these FPGA implementations. It can be observed <sup>367</sup> from these tables that TRV design occupies a much smaller <sup>368</sup> area than NR design. Concretely, TRV design occupies <sup>369</sup> around 75% less area than NR for both exposure times and <sup>370</sup> FPGA devices. In addition to this, the high surface and the <sup>371</sup> more complex structures lower significantly the operating <sup>372</sup> frequency of the circuits. These tables also show how the <sup>373</sup> NR designs in the Spartan 6 and Cyclone II fall short of <sup>374</sup> the reference frequencies of 200 and 50 MHz. For instance, <sup>375</sup> in case of the Spartan 6, the maximum frequency stops at <sup>376</sup>

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TABLE II AREA AND DELAY FIGURES FOR FPGA IMPLEMENTATION USING AN EXPOSURE TIME OF 256 S

	Spartan 6				
Design	Area (Slices)	Ratio	F <sub>max</sub> (MHz)	Ratio	
NR	101	1	30.25	1	
TRV	27	0.27	327.44	0.09	
	Cyclone II				
Design	Area (LEs)	Ratio	F <sub>max</sub> (MHz)	Ratio	
NR	377	1	20.07	1	
TRV	86	0.23	199.20	0.11	

377 29.29 and 30.25 MHz for an exposure time of 128 and 256 s, 378 respectively. A similar situation occurs for Cyclone II devices 379 and NR designs. To effectively use these circuits, a clock 380 divider component should be implemented, increasing thus the area resources. In this sense, TRV designs substantially 381 improve the maximum frequency, increasing around a 90% the 382 383 maximum frequencies. For example, the maximum frequencies supported by TRV designs for Spartan 6 device are 478.87 and 384 385 327.44 MHz for an exposure time of 128 and 256 s, respec-386 tively, which satisfy the required frequency of 200 MHz. As <sup>387</sup> a result, TRV designs in addition to reduce area occupation, 388 allow reaching the required frequencies, without being nec-389 essary to include a clock divider component, which further <sup>390</sup> increase the complexity.

# **IV. CONCLUSION**

This paper proposes and develops a novel measurement 392 <sup>393</sup> algorithm for gas sensors based on single-walled CNTs. This <sup>394</sup> algorithm not only optimizes the sensor performance in terms 395 of time response and sensitivity but also facilitates the inte-396 gration of the sensor in a final system, minimizing hardware resources, and power consumption. 397

The described algorithm is based on the measurement of 398 the variation in resistance over time, what we define as time 399 400 resistance variation (TRV). We demonstrate that only 74 s 401 are necessary to get the maximum performance of the sensor <sup>402</sup> response for ammonia detection and this value is applicable for 403 different recovery strategies (passive desorption, external heat-<sup>404</sup> ing, and dc voltage). In the case of the conventional approach, 405 measuring the NR does not get the best performance below 406 300 s for any of the recovery strategies analyzed. Although 407 both calculations of TRV and NR involve a division, the 408 practical computation of TRV can be reduced by a subtrac-409 tion of two resistance values whereas the division in NR 410 cannot be simplified, because the initial resistance changes 411 over time. Therefore, from a computational point of view and 412 in terms of circuit resources, TRV results in a faster solu-413 tion, requiring a minimal number of electronic blocks for the 414 hardware implementation to extract the sensor information. 415 Thus, the hardware implementation in FPGA of NR and 416 TRV designs has demonstrated that TRV design reduces 417 the area resources and increases substantially the operating 418 frequency.

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